

Title (en)
ANODE USED FOR ELECTROPLATING

Title (de)
ANODE ZUR GALVANISIERUNG

Title (fr)
ANODE POUR ELECTRODEPOSITION

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Abstract (en)
[origin: WO2004059045A2] The invention relates to an anode which is used for electroplating and comprises a basic member and a shield. Said anode is characterized by the fact that additive decomposition is reduced during use thereof in an electroplating process.

IPC 8 full level
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